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## Atomic oxygen resistance of polyimide fibers with phosphorus-containing side chains†

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A series of polyimide (PI) fibers were spun and exposed to atomic oxygen (AO). The PI fibers contained phosphorus in the macromolecular side chain, which was derived from DATPPO diamine. An AO exposure experiment was conducted in a ground-based AO-effect simulation facility. The changes in the surface morphologies and compositions of PI fibers before and after AO erosion were investigated by field emission scanning electron microscopy and X-ray photoelectron spectrometry (XPS). After AO exposure, the phosphorus-containing PI fibers exhibited a denser surface morphology compared with that of the pure PI fibers. XPS results indicated that phosphate species formed on the surfaces of phosphorus-containing PI fibers after AO exposure protected against further erosion. After AO erosion, the mass loss of phosphorus-containing PI fibers was lower than that of pure PI fibers. Moreover, at an AO fluence of  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , the retention of tensile strength and Young's modulus of phosphorus-containing PI fibers were 64.87% and 66.04%, respectively, which were higher than those of pure PI fibers. The results of the current study are crucial for understanding the relationship between polymer structure and AO-resistant properties of PI fibers to develop new materials with low-earth orbit applications.

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## Introduction

Aromatic polyimide (PI) fibers belong to a family of high-performance polymeric fibers.<sup>1</sup> PI fibers are attractive and desirable spacecraft materials because of their excellent thermal stability,<sup>2</sup> good mechanical properties, and outstanding irradiation<sup>3</sup> and chemical resistance.<sup>4</sup> However, almost all polymeric materials and a few metals are damaged both chemically and physically in the space environment, which presents the hazards<sup>5</sup> of high vacuum, high-energy irradiation, thermal cycling, and atomic oxygen (AO). Currently, many satellites, such as observation satellites and space stations, are deployed in low earth orbit (LEO). Although in-orbit<sup>6,7</sup> and ground-simulation experiments have yet to confirm the precise

dangers of AO,<sup>8-10</sup> the dominant chemical constituent in LEO, its destructive potential is substantially increased by high spacecraft speeds. AO is formed when  $\text{O}_2$  molecular bonds are broken by solar photons at wavelengths below  $0.243 \mu\text{m}$ .<sup>11,12</sup> The surfaces facing the direction of travel of the spacecraft are eroded by high AO flux (approximately  $10^{14}$  to  $10^{15}$  atoms per  $\text{cm}^2$  per s) at collision energies of approximately 4.5–5.0 eV. Recent space shuttle flights have demonstrated that interactions between spacecraft surfaces and high-velocity ( $\sim 8 \text{ km s}^{-1}$ ) oxygen atoms within the LEO environment can significantly change the surface properties of many materials, which negatively affect the in-orbital works of a spacecraft.<sup>13</sup>

PI fibers have many excellent properties for space applications, such as irradiation resistance and flame retardancy. However, PI fibers have a poorly resistant to AO. In recent years, polymers containing phenyl phosphine oxide (PPO) groups have been studied extensively for many applications because of their excellent adhesion to metal substrates and good organic solubility. A notable feature of the PPO group is AO resistance. A series of PPO-containing polymers<sup>14</sup> have been designed for durability in the space environment by Connell and co-workers at NASA, Langley Center.<sup>15</sup> Short-term space flight exposure experiments<sup>6,7,14</sup> showed that polymers containing PPO groups have improved AO resistance. Long-term exposure experiments are in progress.

Studies on the effects of AO exposure on the durability of PI fibers have yet to be reported. Based on our previous work,<sup>16</sup> we designed and prepared a series of PI fibers containing PPO

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† Electronic supplementary information (ESI) available: Mass loss of PI fibers versus AO exposure with difference fluence, retention of tensile strength and Yong's modulus of the fibers after AO exposed at  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , ground-based AO effects simulation facility, (a) vacuum chamber, (b) sample tray, the schematic diagram of tensile testing for PI fiber, XPS survey spectra of fibers with and without AO exposure [a] PI-0, [b] PI-2, [c] PI-4, [d] PI-6, high resolution XPS C 1s, O 1s, N 1s spectra of PI fibers before and after exposed to AO [a] PI-0, [b] PI-2, [c] PI-4, [d] PI-6, and high resolution XPS P 2p spectra of PI fibers before and after exposed to AO [a] PI-2, [b] PI-4, [c] PI-6. See DOI: 10.1039/c6ra26941a



groups as pendent substituents, and then exposed fibers to AO beams. This study aims to (1) illustrate the effect of phosphorus content on the AO resistance of phosphorus-containing PI fibers, (2) demonstrate the relationship between the polymer structures and AO-resistant properties of phosphorus-containing PI fibers, and (3) propose a schematic illustration for the mechanism that confers the AO resistance of phosphorus-containing PI fibers.

## Experimental section

### Materials

*N,N'*-Dimethylacetamide (DMAc) was purchased from Tianjin Fine Chemical Co. Ltd. (Tianjin, China) and used as received. 4,4'-Oxydianiline (4,4'-ODA) and 3,3',4,4'-biphenyltetracarboxylic dianhydride (s-BPDA) were purchased from Shanghai Research Institute of Synthetic Resins. s-BPDA was vacuum-dried at 160 °C overnight prior to use. [2,5-Bis(4-aminophenoxy)phenyl] diphenylphosphine oxide (DATPPO) was synthesized according to our previous work;<sup>16</sup> its structure is shown in Scheme 1. All other solvents were used without further purification.

### Fabrication of PI fibers

PPO-containing PAA solutions were synthesized by polycondensation. Briefly, equimolar amounts of two aromatic diamines, ODA and DATPPO, were reacted with s-BPDA (Scheme 1). A mixture containing a 2 : 8 (DATPPO : ODA) molar ratio of diamine to dianhydride in DMAc with a solid content of 15% (w/w) was allowed to react at room temperature for 24 h. PAA solutions were degassed prior to being spun into

fibers. Other PAA solutions with different diamine molar ratios were treated similarly. A diamine ratio exceeding 6 : 4 (DATPPO : ODA) resulted in PAA solutions with viscosities too low for fiber formation. Therefore, diamine ratios were set as 0/10, 2/8, 4/6, and 6/4.

The PAA fibers were prepared *via* a dry-jet wet spinning process, as shown in Fig. 1. The solutions were passed into a coagulation bath through 50-hole spinnerets. Then, the coagulated filaments were passed through a washing bath. The fibers were dried and thermal-imidized followed by collection with a winder. Scheme 1 shows the chemical reaction involved in the fabrication of PI fibers. In addition, Scheme 1 indicates that PAA fibers were converted to PI fibers after thermal cyclization.

### AO exposed testing

The AO irradiation experiment was performed in a ground-based AO effects simulation facility, a type of FDPAO (Filament Discharging Plasma-type Atomic Oxygen Simulation Facility) simulation facility (Fig. S1†). Conditions in the vacuum chamber were as follows: working air pressure of 0.13–0.15 Pa, discharge voltage of 118–200 V, and discharge current of 200

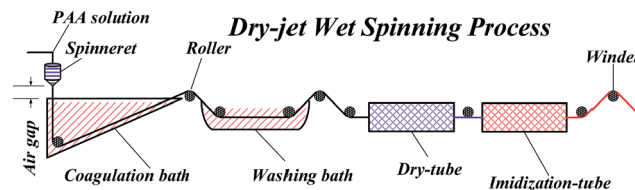
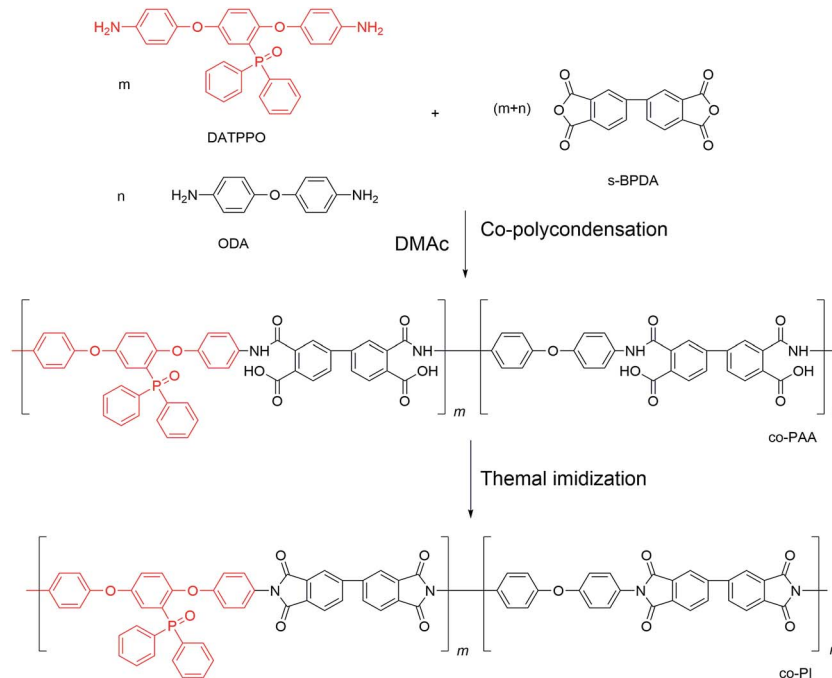


Fig. 1 Fabrication processing flowchart of PI fibers.



Scheme 1 The fabrication flowchart of PI fibers.



Table 1 AO exposure testing conditions

Medial AO flux, atoms per cm <sup>2</sup> per s	Hours, (h)	Total fluence, (atoms per cm <sup>2</sup> )
AO fluence, atoms per cm <sup>2</sup>	5	$8.3 \times 10^{19}$
	10	$1.4 \times 10^{20}$
	15	$2.0 \times 10^{20}$
	20	$2.6 \times 10^{20}$
	25	$3.4 \times 10^{20}$
	30	$5.0 \times 10^{20}$
Vacuum, Pa	0.13–0.15	

mA. Collision ionization and the dissociation of oxygen molecules by electrons formed oxygen plasma. The main components of plasma are O<sub>2</sub>, O<sub>2</sub><sup>+</sup>, O, O<sup>+</sup>, and electrons. Table 1 presents the AO exposure testing conditions.

PI fibers exceeding 20 cm in length were placed on the sample tray in the vacuum chamber. To calibrate exposure flux, standard Kapton® films were randomly placed around the fibers. All the samples were weighed before and after exposure to different levels of AO fluxes. The AO fluence was calculated from the mass loss of Kapton® by the following formula.

$$F = \frac{\Delta M}{\rho A E} \quad (1)$$

where  $F$  is the total AO fluence (atoms per cm<sup>2</sup>),  $\Delta M$  is the mass loss of Kapton® (g),  $\rho$  is the density of Kapton® (1.42 g cm<sup>-3</sup>),  $A$  is the exposure area of Kapton®, and  $E$  is the erosion constant of Kapton® ( $3 \times 10^{-24}$  cm<sup>3</sup> per atom).

## Measurements

Fourier transform infrared (FTIR) spectra were obtained by a VERTEX 70 spectrometer with 32 scans, a resolution of 2 cm<sup>-1</sup>, and a KBr background. The surface morphologies of fibers were examined by FESEM (XL30 ESEM FEG). To analyze the elemental components and valence variations of the fiber surfaces before and after AO exposure, X-ray photoelectron spectra (XPS) were recorded by ESCALAB 250Xi with monochromatic Al K<sub>α</sub> X-ray source. To eliminate charge effects, the carbon 1s (284.8 eV) peak was taken as a reference from contaminated hydrocarbon. All the peaks were fitted by XPS software (Avantage) incorporated as described in NIST XPS database (<http://srdata.nist.gov/xps/Default.aspx>). Mechanical properties were measured by an XQ-1 instrument with ASTM standard (D3379-75, edition 1987) at a drawing rate of 20 mm min<sup>-1</sup>. As shown in Fig. S2,† the single filament fiber was first fixed on a paper holder with glue. The paper holder was then cut along the dotted line. More than 10 monofilaments per sample were tested. The final value of the sample was characterized with the averaged data.

## Results and discussion

### Preparation of PI fibers

Pure PI fibers were prepared with the commercially available diamines ODA and s-BPDA. All co-PI fibers were prepared with

DAMPO, ODA, and s-BPDA *via* dry-jet wet spinning process and heat drawing process. The chemical structures of the resulting fibers were characterized by FTIR. FTIR results are shown in Fig. 2. All the PI fibers showed four special peaks at 1771, 1712, 1368 and 736 cm<sup>-1</sup> that corresponded to asymmetrical C=O stretching of imide groups, symmetrical C=O stretching of imide groups, C–N stretching, and C=O bending of the imide ring, respectively. In addition, PAA fiber peaks at 1660 cm<sup>-1</sup> for amide-I and 1550 cm<sup>-1</sup> for amide-II in the spectra disappeared, indicating that PI fibers were successfully prepared. Moreover, the intensities of P=O group peaks at 1465 and 1191 cm<sup>-1</sup> increased as DATPPO content increased, indicating that different diamine DATPPO concentrations were successfully incorporated into the polymers.

### AO exposure results

**Surface morphologies.** Fig. 3 shows that both the pure PI fibers and phosphorus-containing PI fibers had smooth surfaces before AO erosion. Exposure to AO resulted in rough surfaces. The surface roughness increased as AO total fluence increased from 0 to  $5.0 \times 10^{20}$  atoms per cm<sup>2</sup>. Under low AO fluence (*i.e.*  $8.3 \times 10^{19}$  atoms per cm<sup>2</sup>), the surface roughness of all the fibers was not significantly different. However, the surface of the pure PI fibers had a sparse, carpet-like appearance, whereas those of the phosphorus-containing fibers had a dense, carpet-like appearance under higher AO fluence, *i.e.*  $2.6 \times 10^{20}$  atoms per cm<sup>2</sup> and  $5.0 \times 10^{20}$  atoms per cm<sup>2</sup>. The surface roughness of the fibers improved significantly under the same AO fluence as the phosphorus content of the fibers increased from 0% to 60%. Furthermore, the diameter of the phosphorus-containing PI fibers remained constant before and after AO erosion, unlike that of pure PI fibers, which exhibited decreased diameters. These results indicated that the phosphorus-containing PI fibers are resistant to AO.

**Surface element analysis by XPS.** The variations in the oxidation states of the fibers' surface chemical compositions before and after AO exposure were investigated by XPS. XPS results are shown in Fig. S3† and Table 2. The O 1s, N 1s, and C 1s peaks were observed in the XPS curves of pure PI fibers and phosphorus-containing PI fibers before AO exposure. After AO

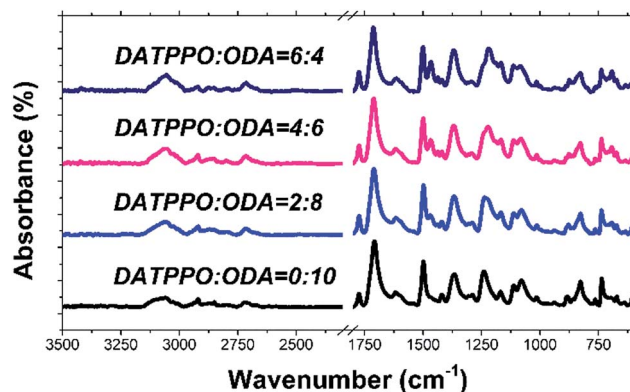


Fig. 2 FTIR spectra of PI fibers with different DATPPO content.





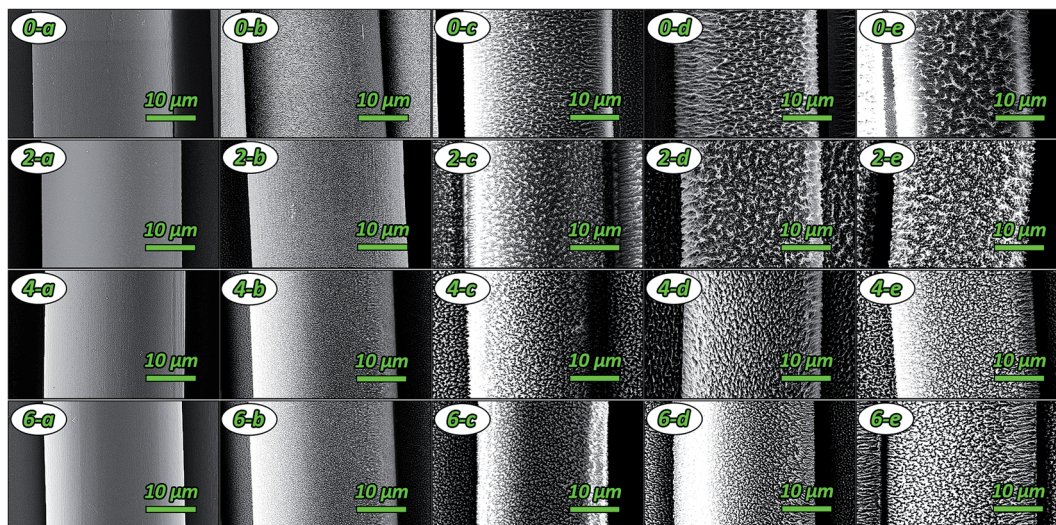


Fig. 3 The surface morphologies of pure PI fibers and phosphorus-containing PI fibers after exposed to AO beam with fluence at (a) 0, (b)  $8.3 \times 10^{19}$  atoms per  $\text{cm}^2$ , (c)  $2.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , (d)  $2.6 \times 10^{20}$  atoms per  $\text{cm}^2$  and (e)  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ .

exposure, the XPS curve of pure PI fibers did not change, whereas P 2s and P 2p peaks emerged in the XPS curves of phosphorus-containing PI fibers. According to quantitative analysis (Table 2), AO exposure drastically decreased relative carbon concentration and significantly increased oxygen and phosphorus concentrations. Carbon content decreased from 75.49% to 64.67% for PI-0, from 71.92% to 58.63% for PI-2, from 73.90% to 61.61% for PI-4, and from 76.12% to 47.09% for PI-6. Phosphorus content increased from 0.76% to 5.92% for PI-2, from 0.85% to 7.04% for PI-4, and from 1.24% to 10.28% for PI-6. These results indicated that phosphorus-containing matter was deposited on the surface after phosphorus-containing fibers exposing AO. Additionally, carbon elements on the surface of fibers were oxidized by AO and released as volatiles.<sup>17–19</sup>

High-resolution XPS spectra of the C (1s), O (1s), N (1s) and P (2p) peaks corresponding to fibers before and after AO exposure were fitted. The results are shown in Fig. S5–S7.† Fig. S4† shows the C 1s spectra of fibers before and after AO exposure. The C 1s spectra were fitted by the C–C species at 284.8 eV binding energies (BEs), the C–N or C–O species at 286.0 eV BEs, and the C=O species at 288.3 eV BEs. Duo and co-workers<sup>20</sup> reported that the binding energy at 284.8 eV is related to the carbon atoms of benzene rings, the binding energy at 286.0 eV is from

C–O–C in ODA or C–N–C in the imide ring, and the binding energy at 288.3 eV is from C=O in the imide ring. As listed in Table 3, AO exposure significantly decreased the peak area of all the fibers at 284.8 eV and increased the peak areas at 286.0 and 288.3 eV. Fibers were degraded as the C–C bond in the benzene ring simultaneously formed a C–O bond or a C=O bond after AO exposure. In addition, oxygen atoms reacted with carbon atoms to generate  $\text{CO}_2$ .<sup>21–23</sup>

The O 1s spectra were also fitted with three peaks that represented P=O species at 531.1 eV, the C=O bond at 532.0 eV, and P–O and C–O bonds at 533.0 eV. As shown in Table 3 and Fig. S5,† after AO exposure, the peak area of the pure PI fibers at 532.0 eV decreased from 83% to 50.1%, whereas the peak area at 533.0 eV increased from 17% to 49.9%. Results for the phosphorus-containing PI fibers showed that all the peak areas at 533.0 eV increased after AO exposure, whereas those at 531.1 eV and 532.0 eV decreased. These results illustrated that C=O bonds in imide rings and O–C and P–O bonds were simultaneously formed when fibers suffered an AO attack.

The N 1s core-level spectra consisted of two peak components at 400.2 eV and 402.0 eV, which were associated with the species of N–C bond and –N= bond, respectively. The peak area of pure PI fibers at 400.2 eV did not change before and after AO

Table 2 Results of surface element analysis before and after AO exposure

Sample element	Element concentration (atoms%)							
	PI-0		PI-2		PI-4		PI-6	
Peaks	Before AO	After AO	Before AO	After AO	Before AO	After AO	Before AO	After AO
C 1s	75.49	64.67	71.92	58.63	73.90	61.61	76.12	47.09
O 1s	19.52	29.94	21.88	30.25	20.74	26.75	18.80	37.55
N 1s	4.99	5.40	5.44	5.20	4.50	4.59	3.83	5.07
P 2p	—	—	0.76	5.92	0.85	7.04	1.24	10.28



attack (Table 3 and Fig. S6†). However, the peak areas of the phosphorus-containing fibers at 400.2 eV decreased significantly, and a new  $\text{-N=}$  bond peak emerged at 402.0 eV after AO exposure. In fact, the peak associated with the  $\text{-N=}$  bond was formed *via* the oxidation of the imide ring when phosphorus-containing fibers were attacked by AO.

The P 2p spectra was fitted with two peaks at 132.2 eV (P–Ar) and 133.2 eV (P=O) (Fig. S7† and Table 3). The peak of the phosphorus-containing PI fibers at 132.2 eV disappeared and the peak areas at 133.2 eV significantly increased after AO attack. These results illustrated that AO erosion destroyed the bond of P–Ar. Therefore, phosphorus existed in the fibers as P=O, *i.e.* phosphates. Consequently, the passivated phosphate layer can effectively prevent surface erosion by AO, resulting in the dense surface morphologies of fibers.

**Mass loss.** Mass loss was observed when the PI fibers suffered AO erosion. Fig. 4 and Table S1† show that the mass loss of all the PI fibers increased significantly as AO fluence increased. We utilized Kapton® film as a reference for mass

loss. Mass loss showed a linear relationship with increased AO fluence. However, both the pure PI fibers and phosphorus-containing PI fibers exhibited nonlinear mass loss in response to AO fluence (Fig. 4). As AO fluence increased from  $8.3 \times 10^{19}$  to  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , the mass loss of the materials increased from 0.35 to 2.1  $\text{mg cm}^{-2}$  for Kapton® film, from 0.35 to 1.8  $\text{mg cm}^{-2}$  for pure PI fibers, from 0.35 to 1.4  $\text{mg cm}^{-2}$  for PI-2, from 0.35 to 1.05  $\text{mg cm}^{-2}$  for PI-4, and from 0.25 to 0.75  $\text{mg cm}^{-2}$  for PI-6. At lower AO fluence ( $8.3 \times 10^{19}$  atoms per  $\text{cm}^2$ ), the mass loss of all the PI fibers, except for PI-6, were the same at 0.35  $\text{mg cm}^{-2}$ , whereas the mass loss of PI-6 was 0.25  $\text{mg cm}^{-2}$ . Moreover, mass loss increased under higher AO fluence. Mass loss decreased as the phosphorus content of the fibers increased. When the AO fluence was set at  $3.4 \times 10^{20}$  and  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , the mass loss of the fibers decreased from 1.2 to 0.6  $\text{mg cm}^{-2}$  and from 1.80 to 0.75  $\text{mg cm}^{-2}$  as the phosphorus content of the fibers increased from 0% to 60%. These results indicated that the incorporating PPO groups into

Table 3 Fitted relative content for C 1s, O 1s, N 1s, P 2p high resolution

Element peaks	Before AO exposure			After AO exposure			
	B. E. (eV)	Assignments	Area (%)	B. E. (eV)	Assignments	Area (%)	
PI-0	C 1s	284.8	C–C	284.7	C–C	71.5	
		285.9	C–N, C–O	286.0	C–N, C–O	15.5	
		288.3	C=O	288.3	C=O	13	
	O 1s	531.5	O=C	531.4	O=C	50.1	
		533.1	O–C	532.7	O–C	49.9	
		400.15	N–C	400.12	N–C	100	
PI-2	C 1s	284.7	C–C	284.8	C–C	72.8	
		285.8	C–N, C–O	286.1	C–N, C–O	15.5	
		288.3	C=O	288.5	C=O	10.5	
		531.1	O=P	531.3	O=P	24.6	
	O 1s	531.6	O=C	531.6	O=C	24.6	
		532.8	O–C	532.9	O–C	50.8	
		400.1	N–C	400.3	N–C	89.1	
	P 2p	—	—	402.2	–N=	10.9	
		132.1	P–(C <sub>6</sub> H <sub>5</sub> )	64.3	—	—	
	PI-4	C 1s	133.3	O=P	35.7	134.2	O=P
284.7			C–C	81.8	284.8	C–C	73.5
285.9			C–N, C–O	11.9	286.1	C–N, C–O	18.1
O 1s		288.4	C=O	6.3	288.4	C=O	8.4
		531.0	O=P	27.9	531.3	O=P	13.9
		531.7	O=C	48.8	531.8	O=C	32.3
		533.0	O–C	23.3	532.9	O–C	53.8
N 1s		400.1	N–C	100	400.2	N–C	70.5
		—	—	—	402.1	–N=	29.5
P 2p		132.1	P–(C <sub>6</sub> H <sub>5</sub> )	67.3	—	—	
	133.1	O=P	32.7	134.2	O=P	100	
PI-6	C 1s	284.8	C–C	83.4	284.7	C–C	72.1
		286.1	C–N, C–O	10.4	286.0	C–N, C–O	18.8
		288.5	C=O	6.2	288.5	C=O	9.1
		531.1	O=P	21.9	531.1	O=P	8.7
	O 1s	531.7	O=C	40.3	531.5	O=C	44.3
		532.9	O–C	37.8	532.8	O–C	47.0
		400.2	N–C	100	400.4	N–C	87.5
		—	—	—	402.0	–N=	12.5
	P 2p	132.0	P–(C <sub>6</sub> H <sub>5</sub> )	45.5	—	—	
		132.9	O=P	54.5	134.1	O=P	100



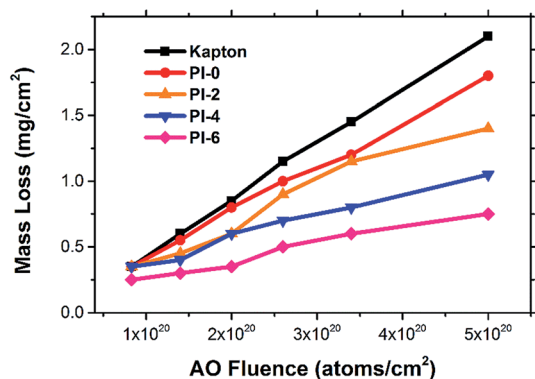


Fig. 4 Mass loss of PI fibers versus AO fluence.

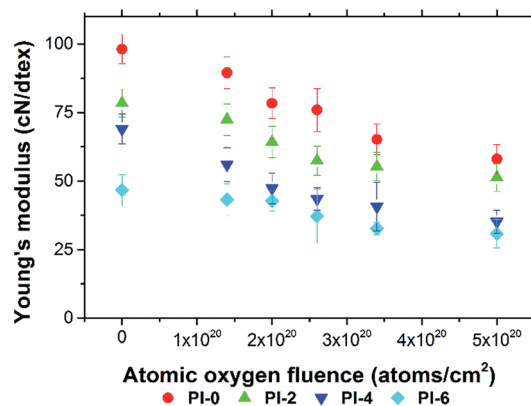


Fig. 6 Young's modulus of fibers versus AO fluence.

the polymer backbone and increasing phosphorus content can improve the AO resistance of PI fibers.

**Mechanical properties of fibers.** Fig. 5–7 show the changes in tensile strength, Young's modulus, and elongation of the pure PI fibers and phosphorus-containing PI fibers under various levels of AO fluence. The plots show that as AO fluence increased from 0 to  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , the tensile strength of the fibers decreased from 6.07 to 2.90 cN per dtex for PI-0, from 5.29 to 2.64 cN per dtex for PI-2, from 4.40 to 2.26 cN per dtex for PI-4, and from 2.79 to 1.81 cN per dtex. The Young's modulus of the fibers decreased from 98.07 to 58.01 cN per dtex, from 78.49 to 51.26 cN per dtex, from 69.00 to 35.23 cN per dtex, and from 46.67 to 30.82 cN per dtex for PI-0, PI-2, PI-4, and PI-6, respectively. Meanwhile, under the AO fluence of  $5.0 \times 10^{20}$  atoms per  $\text{cm}^2$ , the retention of tensile strength and Young's modulus of the fibers increased from 47.78% to 64.87%, and from 59.15% to 66.04%, as phosphorus content increased from 0% to 60% (Table S2<sup>†</sup>). However, the elongation of the fibers did not change before and after AO exposure. Before exposure to various AO levels, the elongation values of the fibers were 15.37%, 25.15%, 33.38%, and 36.93%. After AO exposure, the average values of the fibers were 16.39%, 26.45%, 35.67%, and 39.17% for PI-0, PI-2, PI-4, and PI-6, respectively. These results indicated that incorporating phosphorus into PI fibers can

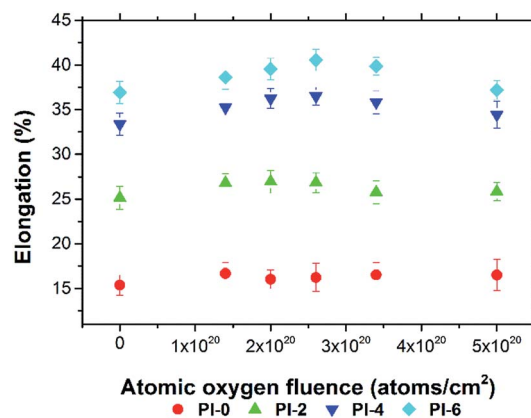


Fig. 7 Elongation of fibers versus AO fluence.

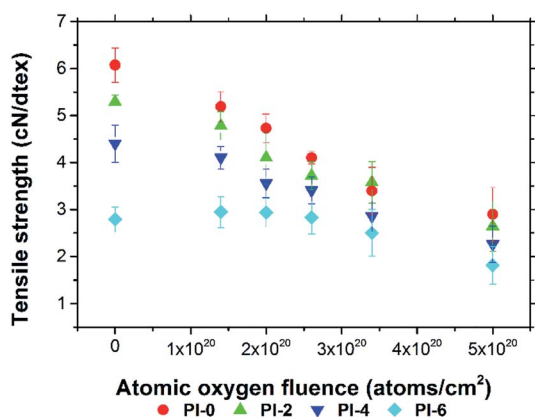


Fig. 5 Tensile strength of fibers versus AO fluence.

improve AO-resistance, and that the retention of tensile strength and Young's modulus of the fibers can increase with increased phosphorus content. Additionally, the tenacity of all the fibers revealed no clear changes before and after AO exposure.

**Mechanism of resistant to AO-exposure.** Based on the above results, the mass loss of PI fibers decreased with increase of phosphorus content in the same irradiation fluence, when PI fibers exposed AO beams. Fig. 8 shows the proposed mechanism of phosphorus-containing PI fibers resistance to AO. According to the XPS results, the C content decreased, simultaneously, the P and O contents increased dramatically. Moreover, the P 2p peak at 132.2 eV disappeared and the P 2p peak at

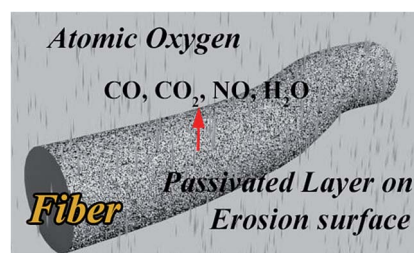


Fig. 8 Schematic illustration of AO eroding fibers.





133.2 eV increased after AO attack. This is a direct evidence of forming a passivated layer on the surface. The hydrocarbons in the polymers were decomposed by AO, and some volatile products (CO or CO<sub>2</sub>, NO, and H<sub>2</sub>O) have been removed from the surface, resulting in mass loss and the rough surface of the fibers. Simultaneously, non-volatile phosphates formed a passivated layer that prevented further AO-induced surface erosion.<sup>24–26</sup>

## Conclusions

A series of PI fibers with phosphorus-containing side chains were prepared. The AO-resistant properties of the fibers after exposure to various levels of AO fluences were investigated systematically. After AO exposure, the surface morphologies of the phosphorus-containing PI fibers were denser, carpet-like in appearance compared with those of the pure PI fibers. Fibers with 60% phosphorus content had denser surfaces under higher AO fluences. XPS showed that a passivated layer of phosphates (O=P(OR)<sub>3</sub>) that prevented further AO erosion formed on the surface of phosphorus-containing PI fibers after AO exposure. Mass loss of the fibers occurred after AO exposure. However, as the phosphorus content of PI fibers increased from 0% to 60%, mass loss decreased significantly from 1.80 mg cm<sup>-2</sup> to 0.75 mg cm<sup>-2</sup> under the highest AO fluence of 5.0 × 10<sup>20</sup> atoms per cm<sup>2</sup>. The mechanical properties of the fibers before and after AO exposure were also investigated. As AO fluence increased, the tensile strength and Young's modulus of the fibers decreased. However, phosphorus-containing PI fibers had lower reductions in measurements. As phosphorus content increased from 0% to 60%, the retention of tensile strength and Young's modulus of the fibers significantly increased from 47.78% to 64.87%, and from 59.15% to 66.04% at the AO fluence of 5.0 × 10<sup>20</sup> atoms per cm<sup>2</sup>. The elongation of the fibers did not change after AO erosion. The results of this study indicate that phosphorus-containing PI fibers have excellent AO-resistant properties, making them crucial materials for use in the LEO environment.

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